



In re application of: Ricci *et al.*

Application No.: 09/408,921

Filed: September, 30, 1999

Title: PRETREATED GAS DISTRIBUTION PLATE

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PATENT

Attorney Docket No.:
LAM1P118/P0539

Examiner: A. Powell

Group: 1763

#11C NR
(6/27/02
MW)

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail to: Commissioner for Patents, Washington, DC 20231 on June 11, 2002.

Signed:


Mia Mitchell-Haynes

AMENDMENT AFTER FINAL

Commissioner for Patents
Box Non-Fee Amendment
Washington, D.C. 20231

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Sir:

Please consider the following amendments and remarks in response to the Final Office Action mailed on April 11, 2002. Applicants respectfully request reconsideration of the captioned application in view of the following remarks and amendments.

IN THE CLAIMS

Please enter the following amendments after final in the claims:

1. (Three Times Amended) A gas distribution plate for use in a semiconductor fabrication apparatus including a semiconductor processing chamber, the gas distribution plate comprising:

USSN 09/408,921
LAM1P118/P0589/CDT/WJP

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